

REMARKS

The undersigned thanks Examiner Cameron for the courtesies extended during several conversations during the period of April 15 to 22, 2004, regarding correction of formalities to get this case into condition for allowance.

The undersigned called the Examiner on around April 14, 2004, to inquire the status of this case. Subsequently, the Examiner discussed this case with the Special Programs Examiner and returned a called to the undersigned. The Examiner said that according the Special Programs Examiner the reissue oath is not in compliance with MPEP 1414 II, which states:

In identifying the error, it is sufficient that the reissue oath/declaration identify a single word, phrase, or expression in the specification or in an original claim, and how it renders the original patent wholly or partly inoperative or invalid. The corresponding corrective action which has been taken to correct the original patent need not be identified in the oath/declaration. If the initial reissue oath/declaration "states at least one error" in the original patent, and, *in addition*, recites the specific corrective action taken in the reissue application, the oath/declaration would be considered acceptable, even though the corrective action statement is not required.

In particular, the Special Programs Examiner has relied on the statement that "the reissue oath/declaration identify a single word, phrase, or expression in the specification or in an original claim" that is an error.

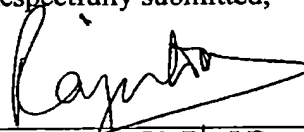
The original oath states: "At least one error upon which reissue is based is described as follows: Claim 1 includes an additional, non-necessary step, which is corrected by the addition of claim 12." A review of claims 1 and 12 shows that the additional, non-necessary step is "baking the substrate after said contacting step and coating step." While Applicants respectfully protest that it is far to late to raise an issue like this, which is of a minor and obvious nature from looking at the record, Applicants herewith submit a supplemental oath which clearly states that the additional, non-necessary step is "baking the substrate after said contacting step and coating step."

Besides, when the undersigned spoke to the Examiner, she said that the specification of the reissue applications must also refer to the parent and related application, particularly, Ogawa reissue RE37,698, issued May 14, 2002.

In the event that the transmittal letter is separated from this document and the Patent and Trademark Office determines that an extension and/or other relief is required, applicants petition for any required relief including extensions of time and authorize the Commissioner to charge the cost of such petitions and/or other fees due in connection with the filing of this document to Deposit Account No. 03-1952, Ref. 356972000230.

Dated: May 6, 2004

Respectfully submitted,



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